Overview of the ATLAS Insertable B-Layer (IBL) Project

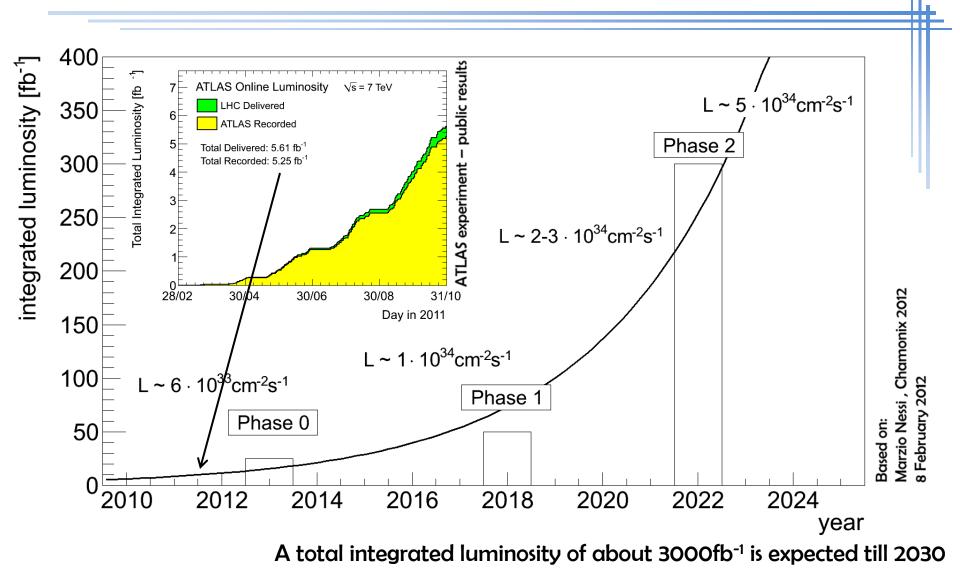
Christian Gallrapp (CERN)

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on behalf of the ATLAS collaboration

LHC UPGRADE PROGRAM

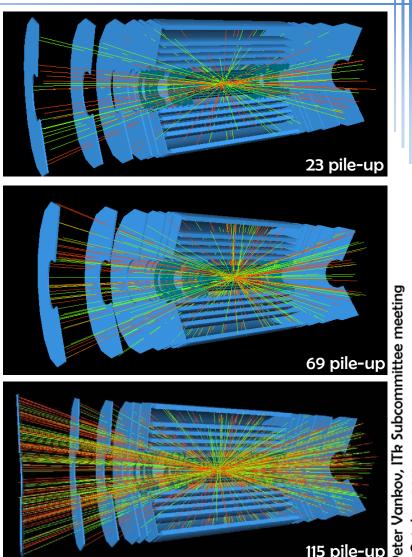
LHC upgrade program



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Challenges for the Inner Detector

- Increased luminosity
 - Higher hit-rate capability
 - Higher segmentation
 - Higher radiation hardness
 - Lighter detectors
- Radiation hardness for the innermost layer at 3cm to 4cm
 - Phase 1: 1.10¹⁵ n_{eq}cm⁻²
 - Phase 2: $5 \cdot 10^{15} n_{eq} cm^{-2}$
 - HL-LHC: 2.10¹⁶ n_{eq}cm⁻²



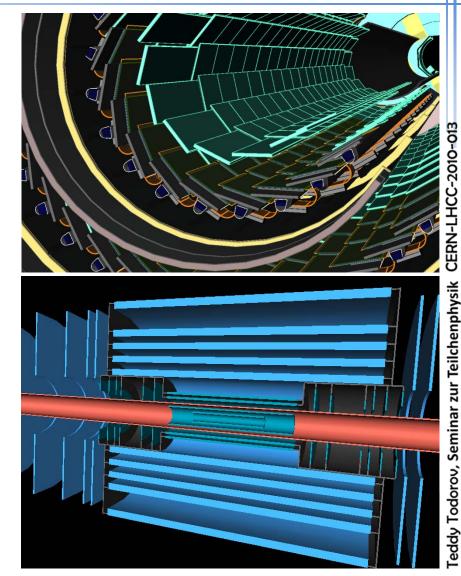
ATLAS Pixel Detector upgrade

Phase O Upgrade

The new IBL will extend the pixel detector system to a 4-layer system with finer segmentation and at a smaller radius

Phase 2 Upgrade

Complete new ATLAS tracker for pixels and strip detectors



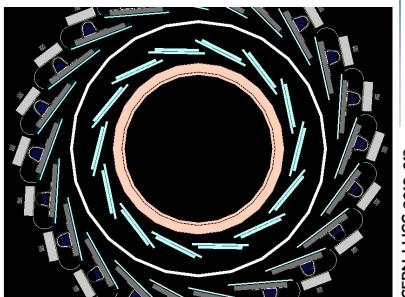
November 2011

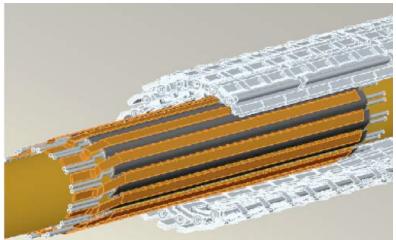
IBL UPGRADE

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IBL upgrade

- IBL Properties
 - Smaller beam pipe (R_{min} = 26.5 mm)
 - Smaller z pitch (250µm)
 - Material budget adjusted to 1.5% XO
 - 250 Mrad TID and 5·10¹⁵ n_{eq}cm⁻² NIEL
- Layout is based on performance studies within the ATLAS Simulation framework and the available space
- Fourth pixel layer for tracking in ATLAS
- Maintain and improve physics performance (b-tagging, light jet rejection) until HL-LHC
- IBL layout
 - 14 staves
 - 32 FE-I4 chips per stave
 => 448 FE-I4 chips in total
 - Available Sensor technologies
 - 3D sensors as single chip modules
 - Planar sensors as double chip modules

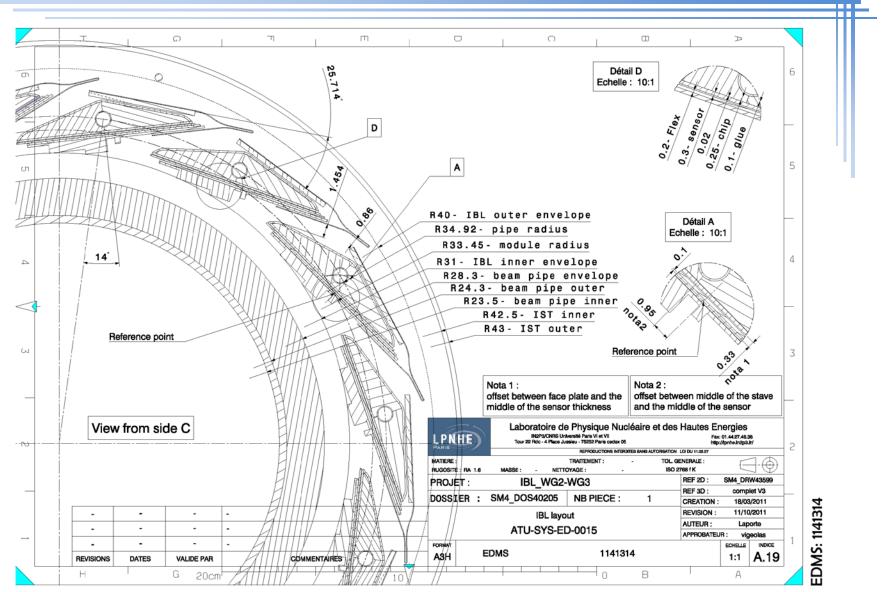




IBL Requirements and Specifications

- Higher radiation hardness
 - 5.10¹⁵ n_{ea}cm⁻² NIEL (Improve radiation hardness by factor 5)
 - max. power dissipation: 200 mW cm⁻² at -15°C
 - tracking efficiency > 97%.
- New readout chip with fine segmentation, more active area and improved hit-rate capability
 - New readout architecture and smaller cell size 250.50 μm^2
 - Large single-chip (21·19mm²)
 - Radiation hardness > 250Mrad TID
- Lighter detector: less radiation length in support and cooling
 - improve radiation length per layer from 2.7% to ~ 1.5% to minimize multiple scattering in closest layer
 - Requires lighter and less material for support and cooling
 - High efficiency CO_2 cooling at -40°C coolant temperature
- New off-detector readout system
 - Matched to FE-I4 pixel chip
 - Increase readout speed by a factor of two





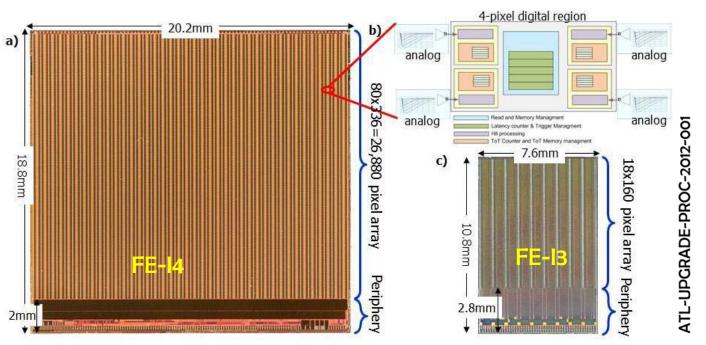
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ATLAS FE-I4

- Smaller pixels (50.250 µm²)
- Lower noise and threshold operation
- Compatibility for higher data rates
- Column drain architecture with local hit storage
- Largest chip to date in HEP:
 - maximize active area and reduce bump-bonding costs
- array size: 80 col. x 336 rows
- => 26880 pixels, 8x10⁷ transistors
- average hit rate at 1% inefficiency
 => 400 MHz cm⁻²; max. trigger rate: 200kHz



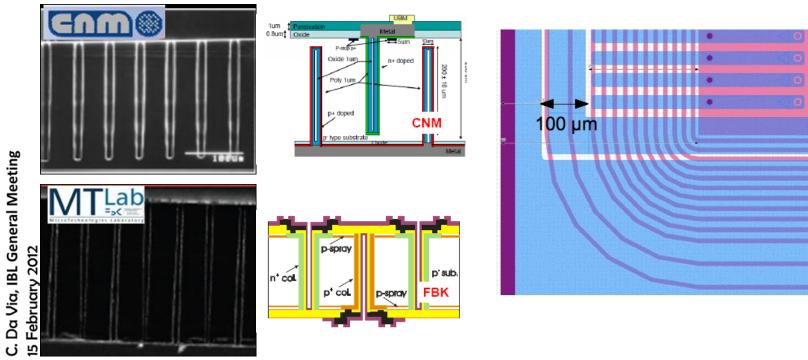
IBM 130nm process

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IBL Sensors Technologies

3D slim edge (FBK, CNM)

- Horizontal depletion (short depletion width leads to low bias voltage)
- Different processing but common top-layer mask for chip connection
- Manufacturing yield now being tested with pre-production runs by CNM and FBK



Planar n-in-n slim edge (CiS)

- minimize inactive edge by shifting guard rings underneath active pixel region
- Ongoing efficiency studies after full IBL irradiation
- Manufactured by CiS like present pixel sensors

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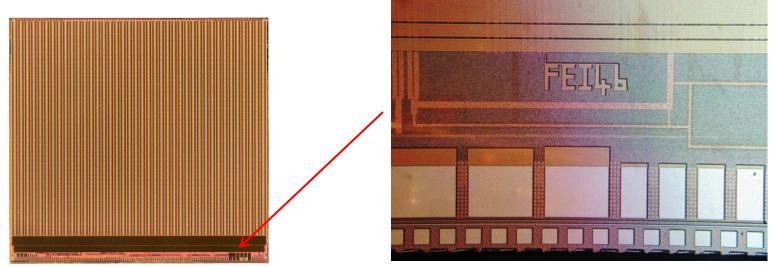
MODULES AND STAVE

IBL modules

3D n-in-p sensor Property Planar n-in-n sensor 16.8 x 20.0 Active size W x L [mm²] 16.8 x 40.9 18.8 x 20.5 Total size W x L [mm²] 18.54 x 41.27 230 Thickness [µm] 200 ≤ 15 Typical depletion voltage [V] ≤ 35 25 Typical initial operation voltage [V] 60 180 Operation voltage at the end of lifetime [V] 1000			
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A A A B Constant and the state of the state	25	Typical initial operation voltage [V]	60
1500 3D sensors as single chip modules	180	Operation voltage at the end of lifetime [V]	1000
Pay 21200	3D sensors as single and a sensor a s	hip modules B B C C C C C C C C C C C C C	B 0.450 Long pixels 0.450 Long pixels 0.450 Long pixels 0.450 Long pixels 0.450 Long pixels 0.450 Long pixels IBL 2-chip planar sensor tile Rev. 08.08.2010

IBL module production (I)

- Decision to install IBL in 2013 came in January 2011
 - Crash program to submit production version of chip in a few months
- Verification of new FE-I4B chip
 - Chip "has to work"
- Submission and tests
 - 16 wafers received in December 2011 and 8 wafer in February 2012
 - One diced wafer at LBNL by December 2011
 - 2 chips tested and in beam at LANL by December 2011

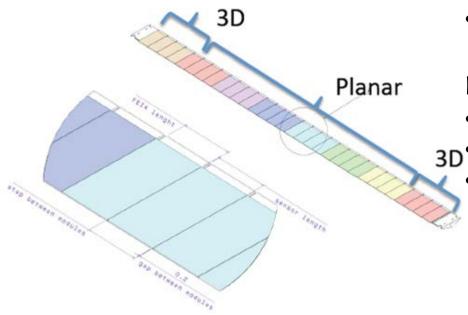


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IBL module production (II)

ATLAS Pixel extended Institute Board endorsed the recommendation of the review panel:

- produce enough Planar sensors to build 100% of the IBL
- continue current 3D sensor production to build 25% of the IBL



3D n-in-p sensor

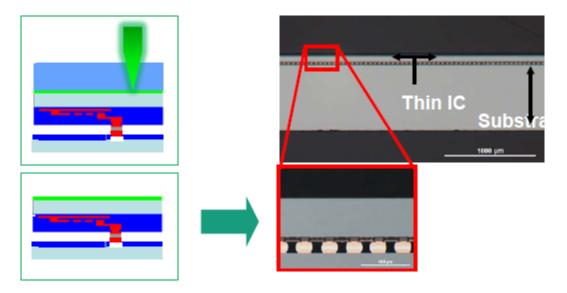
- 6 batches in production: 3 at CNM and 3 at FBK, the first 3 batches will go to IZM for bump-bonding
- 49 out of 50 selected wafer available
- first batch now at IZM for bump-bonding

Planar n-in-n sensor

- 6 batches in production at CIS
- 119 out of 150 accepted wafer received
- 3 batches at IZM for bump-bonding

IBL bump-bonding

- Over 78 single-chip assemblies with planar and 3D sensors have been bumpbonded for the sensor qualification in 2011
- Thin FE-I4 (100µm and 150µm) on planar and 3D sensors have been prepared by IZM to test the feasibility of thin modules (i.e. final IBL modules):
 - first modules single and double chip have been produced successfully with 100µm and 150µm thick FE-I4A
 - 31 planar double chip and 17 3D single chip modules with thin FE-I4 chips done as preproduction to IBL module specifications



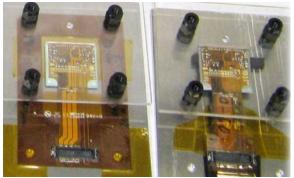
Test results on production chips

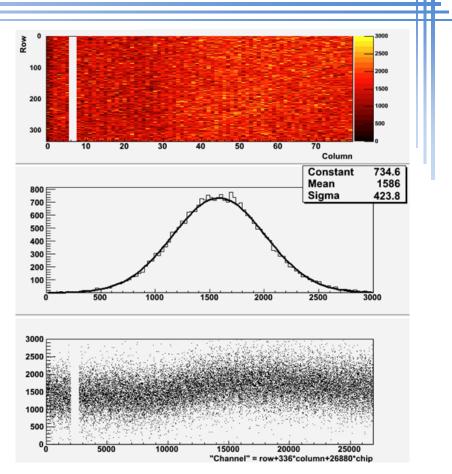
Characterization and tests of FE-I4B:

- 1 single chip tested so far on single-chip cards to test basic functionality and analog part
- New and corrected features with respect to FE-I4A are working fine
- More testing of FE-I4B needed before final conclusion on chip quality
- First chips have been irradiated

Wafer testing:

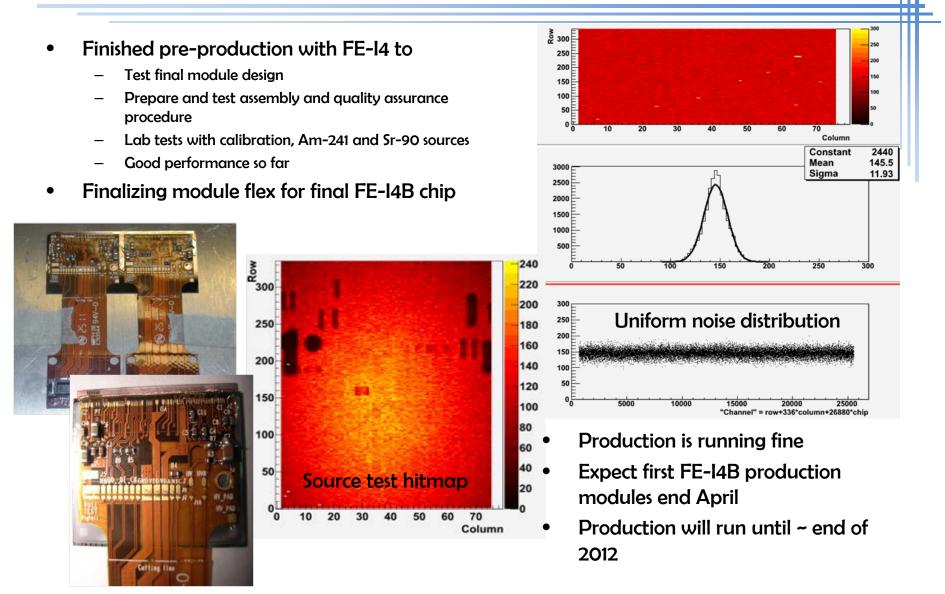
- Tests on FE-I4A wafers (scan chain etc...). Understanding of test results in progress.
- First batch of FE-I4B wafer tests during February -> All indicators are green so-far





Threshold scan of un-tuned chip shows the expected analog response

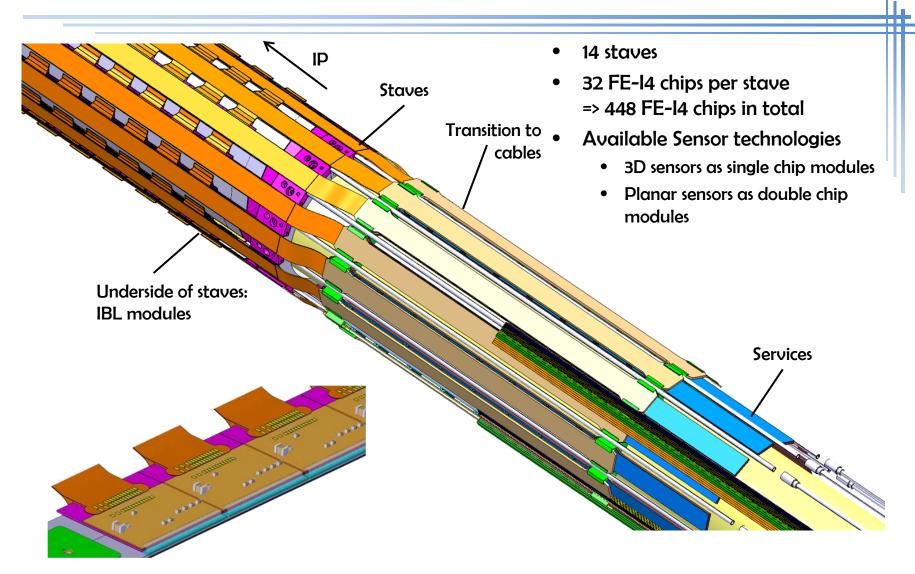
Tests on assembled IBL modules



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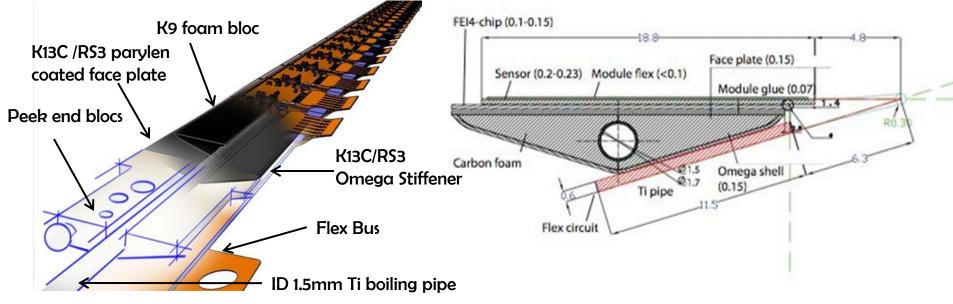
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IBL stave



IBL carbon-fibre support

- Carbon-fibre support structure with minimal material budget X/X_o~0.5% for support and cooling
- Optimized stiffness and thermal conductivity
- Match thermal expansion
- Material qualification for use in high-radiation environments (300Mrad)
- Detector cooling with a CO₂ system working -40°C to minimize the leakage currents of the sensors



Stave production

- Bare stave production running -> 6 of 42 received
 - carbon fiber (K13C) Omega glued on the foam to provide mechanical rigidity and to assure the heat transfer to the central cooling pipe
 - Qualified with pressure tests, brazing to external pipes, deformation survey and flatness of staves and thermal conductivity to cooling pipe

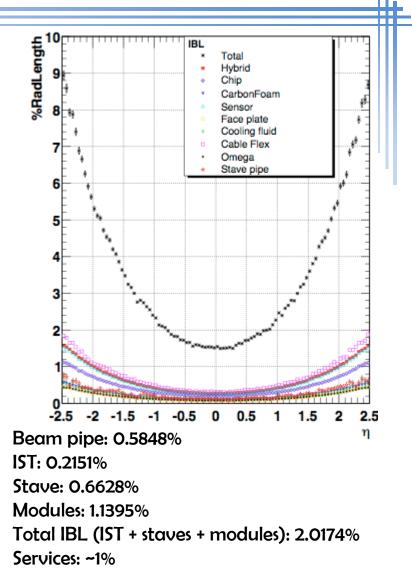
Design:

- Titanium cooling pipe
 - Inner diameter: 1.5mm
 - Wall thickness: 0.1mm
- 3 layer (0/90/0) face plate
- EOS and Central Peek support
- Flex fully glued on the Omega
- Short stave for loading (1300mm)

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IBL Material Budget

- Status of X_o in summer 2011 (end of prototyping):
 - perpendicular incident, smeared over active surface, average over stave length η<3
- Task force in place to monitor actual X_o during construction
- Increase of X_o during prototyping from 1.5% (TDR) to 2.0%
- Decrease of X_o = 1.5% after reduced material budget
- Aim on keeping X_o within reasonable engineering limits



OUTLOOK

IBL schedule overview

Activity	Starting	Ending	
FEI4-B	September 2011: Submission	December 2011 chips received, tests of 1 st batch completed by the end of February 2012	
Bump bonding	August 2011: pre-production	November 2012: Completion (incl. spares)	
Module assembly	End May 2012: 1 st modules ready for loading	December 2012 (spare and contingency incl.)	
Module loading	July 2012: \rightarrow 4 staves to be ready by September 2012	April 2013: Completion (spare and contingency incl,)	
Stave loading	Mar 2012: starting with the 1 st available staves	June 2013: Completion	
Final tests and commissioning	July 2012	September 2013: IBL Installation	

- FEI4B is as scheduled and working fine Wafer tests to survey
- Next key step: module production with FEI4B to demonstrate the electrical functionality of the stave (flex, module, off-detector readout)
- Loading of first stave with pre-production modules is expected around March/April and first production staves July 2012

THANK YOU FOR YOUR ATTENTION

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